



AMENDMENT TRANSMITTAL LETTER				Docket No. N9460.0018/P018
Application No. 10/705,845-Conf. #4874	Filing Date November 13, 2003	Examiner Della Rutledge	Art Unit 2851	
Applicants: Hisayuki Takasu, et al.				
Invention: A METHOD OF DEVELOPING A RESIST FILM AND A RESIST DEVELOPMENT PROCESSOR				
<b>TO THE COMMISSIONER FOR PATENTS</b>				
Transmitted herewith is an amendment in the above-identified application.				
The fee has been calculated and is transmitted as shown below.				
<b>CLAIMS AS AMENDED</b>				
	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate
Total Claims	16	- 20 =		x
Independent Claims	8	- 8 =		x
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>				
Other fee (please specify):				
<b>TOTAL ADDITIONAL FEE FOR THIS AMENDMENT:</b>				0.00
<input checked="" type="checkbox"/> Large Entity		<input type="checkbox"/> Small Entity		
<input type="checkbox"/> No additional fee is required for this amendment.				
<input type="checkbox"/> Please charge Deposit Account No. _____ in the amount of \$ _____. A duplicate copy of this sheet is enclosed.				
<input type="checkbox"/> A check in the amount of \$ _____ to cover the filing fee is enclosed.				
<input type="checkbox"/> Payment by credit card. Form PTO-2038 is attached.				
<input checked="" type="checkbox"/> The Director is hereby authorized to charge and credit Deposit Account No. <u>04-1073</u> as described below. A duplicate copy of this sheet is enclosed.				
<input checked="" type="checkbox"/> Credit any overpayment.				
<input checked="" type="checkbox"/> Charge any additional filing or application processing fees required under 37 CFR 1.16 and 1.17.				
 <span style="float: right;">Dated: <u>April 4, 2005</u></span>				
Mark J. Thronson Attorney Reg. No.: 33,082 DICKSTEIN SHAPIRO MORIN & OSHINSKY LLP 2101 L Street NW Washington, DC 20037-1526 (202) 775-4742				



Docket No.: N9460.0018/P018  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

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In re Patent Application of:  
Hisayuki Takasu, et al.

Examiner: Della Rutledge

Application No.: 10/705,845

Art Unit: 2851

Filed: November 13, 2003

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For: A METHOD OF DEVELOPING A RESIST  
FILM AND A RESIST DEVELOPMENT  
PROCESSOR

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**AMENDMENT**

Commissioner for Patents  
MS: Amendment  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

This paper is in response to the Office Action dated December 2, 2004. Please amend the above-identified U.S. patent application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 7 of this paper.